



S/N 10/081,818

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Jerome M. Eldridge et al.

Examiner: Tu-Tu V. Ho

Serial No.: 10/081,818

Group Art Unit: 2818

Filed: February 20, 2002

Docket No.: 1303.045US1

Title: ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW  
ASYMMETRICAL TUNNEL BARRIER INTERPOLY INSULATORS

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**AMENDMENT AND RESPONSE UNDER 37 CFR § 1.111**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

This responds to the Office Action mailed on April 29, 2005. Please amend the above-identified patent application as follows.